

## **Spin Chuck Questionnaire**

1.	. Chuck Type:	
	□ Recessed	□ Porous Ceramic
	□ Captive	□ Captive
	□ Custom	
2.	Substrate Dimensions:	
	<ul><li>Diameter:</li><li>Thickness:</li></ul>	Tolerance (+/-): Tolerance (+/-):
	OR FOR RECTANGULAR	
	<ul><li>L:</li><li>W:</li><li>H:</li></ul>	Tolerance (+/-): Tolerance (+/-): Tolerance (+/-):
3.	Substrate material:	
4.	Film frame type (for film frame chuck only):	
5.	Spin Coater/Developer Model:	
	□ Apogee □ Apogee 450 □ □	Other
6.	Process type: □ Coat □ Clean	□ Develop
7.	7. Process chemicals to be Used:	
8.	Process objectives (uniformity, coating thickness, edge bead removal, backside rinse, etc.)	

□ No

9. Can you provide a substrate sample for fit? ☐ Yes